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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/955,517	09/18/2001	Cyrus E. Tabery	G0228	8552
7590 11/01/2004			EXAMINER	
Himanshu S. Amin Amin & Turocy, LLP			HASSANZADEH, PARVIZ	
National City C	• •		ART UNIT	PAPER NUMBER
1900 E. 9th Street, 24th floor Cleveland, OH 44114			1763	
			DATE MAILED: 11/01/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Amplication N		
	Application No.	Applicant(s)	/
Advisory Action	09/955,517	TABERY ET AL.	
	Examiner	Art Unit	
The MAN INC DATE of the	Parviz Hassanzadeh	1763	
The MAILING DATE of this communication appe		•	
THE REPLY FILED 26 October 2004 FAILS TO PLACE Therefore, further action by the applicant is required to average final rejection under 37 CFR 1.113 may only be either: (1) condition for allowance; (2) a timely filed Notice of Appea Examination (RCE) in compliance with 37 CFR 1.114.	oid abandonment of this application	ation. A proper reply	y to a
PERIOD FOR RE	EPLY [check either a) or b)]		
a) The period for reply expiresmonths from the mailing			
b)  The period for reply expires on: (1) the mailing date of this A no event, however, will the statutory period for reply expire I ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f).	ater than SIX MONTHS from the mailing	a date of the final rejection	on
Extensions of time may be obtained under 37 CFR 1.136(a). The fee have been filed is the date for purposes of determining the period of fee under 37 CFR 1.17(a) is calculated from: (1) the expiration date of (2) as set forth in (b) above, if checked. Any reply received by the Offic timely filed, may reduce any earned patent term adjustment. See 37 C	of extension and the corresponding amo the shortened statutory period for reply the later than three months after the mail	unt of the fee. The appr	Office action: or
1. A Notice of Appeal was filed on Appellant's 37 CFR 1.192(a), or any extension thereof (37 CFF	Brief must be filed within the pe	eriod set forth in f the appeal.	
2. The proposed amendment(s) will not be entered be	ecause:		
(a) they raise new issues that would require further	er consideration and/or search (s	see NOTE below);	
(b) they raise the issue of new matter (see Note b		,	
<ul><li>(c) \( \sum \) they are not deemed to place the application ir issues for appeal; and/or</li></ul>	n better form for appeal by mate	rially reducing or sin	nplifying the
<ul><li>(d)  they present additional claims without canceling</li><li>NOTE:</li></ul>	ng a corresponding number of fi	nally rejected claims	3.
3. Applicant's reply has overcome the following rejecti	ion(s):		
4. Newly proposed or amended claim(s) would canceling the non-allowable claim(s).		parate, timely filed a	amendment
5. ☐ The a) ☐ affidavit, b) ☐ exhibit, or c) ☐ request for application in condition for allowance because: See	reconsideration has been consideration Sheet	dered but does NOT	place the
6. The affidavit or exhibit will NOT be considered becaraised by the Examiner in the final rejection.		o issues which were	newly
7. For purposes of Appeal, the proposed amendment( explanation of how the new or amended claims wo	(s) a)⊠ will not be entered or b) ould be rejected is provided belo	☐ will be entered a	nd an
The status of the claim(s) is (or will be) as follows:	, , , , , , , , , , , , , , , , , , , ,	э. эррэнаса.	
Claim(s) allowed:			
Claim(s) objected to:			
Claim(s) rejected: <u>1,2,4-20,25 and 26</u> .			
Claim(s) withdrawn from consideration: 21-24.	·		
8. The drawing correction filed on is a) approximately approximatel	oved or b) disapproved by th	ne Examiner	
9. Note the attached Information Disclosure Statemen			
10. Other:	-(σ), 1 το 1 το) 1 αροι Νυ(ο)	<del>-</del>	
			, ,
		P. Hassanza	
		Parviz Hassanzade Primary Examiner	h .

Art Unit: 1763

Continuation of 5. does NOT place the application in condition for allowance because:

On 10/27/04, the Examiner initiated a phone interview with Kavin Dunn (Reg. No. 52,842) to further discuss the invention, and particularly to clarify the limitation "mask creating component fabricating one or more features on an alternative aperture phase shift mask". It was discussed that the prior art method of making such a mask uses a "master mask" as disclosed on page 3 of the specification while the present invention does not use a master mask. The present invention fabricates masks in the absence of a master mask by controlling the mask creating components based on in-situ measurement of the mask feature parameters during the mask creating process.

Examiner suggests that creating mask features directly (in the absence of a master mask) by controlling the mask creating componen based on in-situ measurement of the mask feature paramters is a process limitation. Examiner suggests to positively incorporate the process limitation as a function into a controller such as a control (driving) system configured to control the mask creating components during the mask fabrication based on in-situ measurements of th feature paramters. However, the proposed functional limitation incorporated into a control system would require further search and consideration by the Examiner.